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**(I)** 

### (54) POSITIVE TYPE PHOTOSENSITIVE **IMAGE-FORMING MATERIAL FOR USE** WITH AN INFRARED LASER

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## (\*) Notice:

This patent issued on a continued prosecution application filed under 37 CFR 1.53(d), and is subject to the twenty year patent term provisions of 35 U.S.C. 154(a)(2).

Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

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(58)

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(52)	U.S. Cl.	•••••••••••••••••••••••••••••••••••••••	<b>430/192</b> ; 430/156; 430/270.1; 430/281.1; 430/905; 430/944

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Field of Search ...... 430/156, 270.1,

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#### **ABSTRACT** (57)

A positive type photosensitive image-forming material for use with an infrared laser is provided. The material includes a substrate, a layer (A) containing not less than 50% by weight of a copolymer which contains, as a copolymerization component, not less than 10% by mol of at least one of the following monomers (a-1) to (a-3), wherein (a-1) is a monomer having in the molecule a sulfonamide group wherein at least one hydrogen atom is linked to a nitrogen atom, (a-2) is a monomer having in the molecule an active imino group represented by the following general formula



and (a-3) is a monomer selected from acrylamide, methacrylamide, acrylate, methacrylate and hydroxystyrene, which respectively have a phenolic hydroxyl group; and a layer (B) containing not less than 50% by weight of an aqueous alkali solution-soluble resin having a phenolic hydroxyl group. The layer (A) and the layer (B) are laminated on the substrate in that order. At least the layer (B) contains a compound which generates heat upon absorbing light. The image-forming material has excellent stability of sensitivity with regard to concentration of a developing solution, i.e., has excellent development latitude.

### 20 Claims, 1 Drawing Sheet